

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	13	jp-06236878-\$.did. jp-10256251-\$.did. jp-05315336-\$.did. jp-09069522-\$.did. jp-10284601-\$.did. jp-10022274-\$.did. jp-2001505367-\$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/08/01 15:00
L2	73	(257/762.ccls. 257/767.ccls. 257/768.ccls. 257/751.ccls. 438/627.ccls. 438/643.ccls. 438/653.ccls.) and ((copper cu platinum pt) same (interconnect\$6 diffusion barrier) same (platinum pt osmium os ruthenium ru iridium ir rhodium rh) same (electromigrat\$5 void))	US-PGPUB; USPAT	OR	ON	2005/08/01 15:51
L3	1	"20020006468".pn.	US-PGPUB; USPAT	OR	ON	2005/08/01 15:51
L4	64	((((pt OR platinum) WITH INTERCON\$10)) same (diffusion adj barrier)	US-PGPUB; USPAT	OR	ON	2005/08/01 15:53
L5	391	((RU OR RUTHENIUM or pt or ir or os or rh or iridium or platinum or osmium or rhodium) same electromigration)	US-PGPUB; USPAT	OR	ON	2005/08/01 16:06
L6	1	"6441492".pn.	US-PGPUB; USPAT	OR	OFF	2005/08/01 16:06
L7	243	((((RU OR RUTHENIUM or pt or ir or os or rh or iridium or platinum or osmium or rhodium) and electromigration)) and (copper or cu)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/01 16:08
L8	319	((RU OR RUTHENIUM) and (DIFFUSION ADJ BARRIER))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/01 16:15
L9	36	((RUTHENIUM or iridium or platinum or osmium or rhodium) and electromigration)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/01 16:32
L10	578	((257/762.ccls. 257/767.ccls. 257/768.ccls. 257/751.ccls. 438/627.ccls. 438/643.ccls. 438/653.ccls.) and (copper cu platinum pt) and (platinum pt osmium os ruthenium ru iridium ir rhodium rh)) and (electromigrat\$5 void)	US-PGPUB; USPAT	OR	ON	2005/08/01 17:02
L11	387	257/767.ccls.	US-PGPUB; USPAT	OR	OFF	2005/08/01 17:13

L12	1659	((semiconductor silicon si wafer interconnect\$6 wir\$6 trace) same (((rhodium rh ruthenium ru iridium ir osmium os platinum pt) same (cu copper)) ((rhodium rh ruthenium ru iridium ir osmium os) same (platinum pt)))).clm.	US-PGPUB	OR	ON	2005/08/01 17:19
L13	69	((semiconductor silicon si wafer) same (interconnect\$6 wir\$6 trace) same (((rhodium rh ruthenium ru iridium ir osmium os platinum pt) same (cu copper)) ((rhodium rh ruthenium ru iridium ir osmium os) same (platinum pt)))).clm.	US-PGPUB	OR	ON	2005/08/01 17:20

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L13	69	((semiconductor silicon si wafer) same (interconnect\$6 wir\$6 trace) same (((rhodium rh ruthenium ru iridium ir osmium os platinum pt) same (cu copper)) ((rhodium rh ruthenium ru iridium ir osmium os) same (platinum pt))))).clm.	US-PGPUB	OR	ON	2005/08/01 17:20